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	Application No.	Applicant(s)
Notice of Allowability	10/821,166	MOELLER ET AL.
	Examiner	Art Unit
	Olga Asinovsky	1711
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS (herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGOT THE Office or upon petition by the applicant. See 37 CFR 1.313	ars on the cover sheet with the OR REMAINS) CLOSED in this or other appropriate communication is subjection is subjection.	ne correspondence address s application. If not included ation will be mailed in due course. THIS
1. This communication is responsive to <u>02/13/2006</u> .		
2. The allowed claim(s) is/are <u>1-55</u> .		
<ul> <li>3. Acknowledgment is made of a claim for foreign priority units.</li> <li>a) All b) Some* c) None of the:</li> <li>1. Certified copies of the priority documents have</li> <li>2. Certified copies of the priority documents have</li> <li>3. Copies of the certified copies of the priority documents.</li> </ul>	been received. been received in Application No	o
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONMI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		eply complying with the requirements
4. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give		
5. CORRECTED DRAWINGS ( as "replacement sheets") must	be submitted.	
(a)  including changes required by the Notice of Draftsperso	on's Patent Drawing Review (P	TO-948) attached
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b)  including changes required by the attached Examiner's Paper No./Mail Date	Amendment / Comment or in the	ne Office action of
Identifying indicia such as the application number (see 37 CFR 1.4 each sheet. Replacement sheet(s) should be labeled as such in the		
<ol> <li>DEPOSIT OF and/or INFORMATION about the depose attached Examiner's comment regarding REQUIREMENT F</li> </ol>		
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5 🗆 Nation of Inform	al Patent Application (DTO 452)
2. ☐ Notice of Preferences Cited (PTO-692)  Provided in References Cited (PTO-692)  Provided in References Cited (PTO-692)	in Notice of Inform     interview Summ	al Patent Application (PTO-152)
3. X Information Disclosure Statements (PTO-1449 or PTO/SB/08	Paper No./Mail	Date
Paper No./Mail Date	7. La Caminer s Ame	shamen voormen.
Examiner's Comment Regarding Requirement for Deposit of Biological Material		ement of Reasons for Allowance
	9.  Other	

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The amendment filed on 02/13/2006 is entered.

## Response to Arguments

1. Applicant's arguments, see amendment, filed 02/13/2006, with respect to the present specification inserting the definition of the styrene content for the commercially available product of the SI block copolymer specified at page 5 in the original specification to Kraton D1107, Kraton D1112, Kraton D1113, Quintac 3433N, Quintac 3520, Exxon DPX565, Exxon DPX 586 and Vector 4230 have been fully considered and are persuasive. Applicants have submitted the required evidence that said styrene-isoprene block copolymers have a low styrene content. The rejection of claims 1, 33 and 44 under 112, first paragraph, has been withdrawn.

## **REASONS FOR ALLOWANCE**

2. The following is an examiner's statement of reasons for allowance: The claimed invention is a pressure-sensitive adhesive composition comprising: (a) about 10 to about 40 wt.% of a styrene-isoprene block copolymer having a styrene content of from about 14% to about 20% by weight, (b) about 5 to about 30 wt.% of a styrene-butadiene block copolymer, (c) about 30 to about 65 wt.% of an aromatically modified tackifying resin, and (d) about 8 to about 30 wt.% of a plasticizing oil, for the present independent claims 1 and 44. Also, independent claim 33 discloses a pressure-sensitive adhesive composition having substantially the same chemical formulation that claim 1 and the specified statement that said composition expresses a single glass transition

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temperature and has a tangent delta value of greater than about 0.5 for all temperatures in the range of about minus 20C to about 100 C.

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The closest references of record are Hatfield et al Patent 6,184,285 (primary reference), Tungseth et al Patent 4,001,167, Hansen et al Patent 5,891,957 and Sasaki et al Patent 5,663,228.

While Hatfield discloses an adhesive composition comprising a blend of SI block copolymer, SB block copolymer, tackifying resin and plasticizing oil, Hatfield discloses a SI block copolymer having greater than about 25 wt.% of styrene. The secondary reference Tungseth or Hansen discloses a low styrene content for a SI block copolymer (Tungseth col. 5, line 26 and Hansen col. 6, line 26), however, there is no motivation to combine the teachings in Hatfield with Tungseth or Hansen because Hatfield does not disclose a low styrene content for a SI block copolymer and since Hatfield discloses a hot melt adhesive property. A hot melt construction adhesive has different property that a pressure-sensitive adhesive. There is no motivation to combine the teaching in Hatfield with Sasaki since Hatfield discloses higher styrene content for a SI block copolymer and since none of the references discloses a single tangent delta for the resulting chemical formulation of a pressure sensitive adhesive.

Claims 1-55 are deemed contain allowable subject matter.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Olga Asinovsky whose telephone number is 571-272-1066. The examiner can normally be reached on 9:00 to 5:30 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, James Seidleck can be reached on 571-272-1078. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

0.A.

Feb. 26, 2006

Olga Asinovsky Examiner Art Unit 1711

James J. Seidleok Supervisory Patent Examiner Technology Center 1700